Search Notes



| Application/Control No. | Applicant(s)/Patent Under Reexamination |
|-------------------------|--|
| 10593809 | NARAYAN ET AL. |
| Examiner | Art Unit |
| JONATHAN C LANGMAN | 1794 |

| SEARCHED | | | |
|----------|----------|----------|----------|
| Class | Subclass | Date | Examiner |
| 420 | 427 | 6/4/2009 | JCL |

| SEARCH NOTES | | |
|---|------------|----------|
| Search Notes | Date | Examiner |
| East Text Search, Palm Inventor Search, Non patent Literature Search | 6/4/2009 | JCL |
| Updated East Text Search, Non patent Literature Search, keywords: alpha ta, bcc ta, silicon substrate, native oxide removed, copper diffusion barrier | 11/24/2009 | JCL |
| Updated East Text Search | 6/16/2010 | JCL |
| Updated East Text Search, Palm Inventor Search, Non patent Literature Search | 3/1/2011 | JCL |
| Updated East Text Search | 1/26/2012 | JCL |

| INTERFERENCE SEARCH | | | |
|---------------------|----------|------|----------|
| Class | Subclass | Date | Examiner |
| | | | |

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